

Amendment Under 37 C.F.R. § 1.111  
U.S. Application No. 10,644,964

**IN THE SPECIFICATION:**

Please amend Table 3, by replacing “TaB (Ta:B=4:1) with --Ru--.”

A new page 29 incorporating the amendment is attached herewith.

Table 3

Example 3 (Heating Condition 200 °C, 60 min)

In case where the stress correction film is formed on the multilayer reflection film

	Material	Film Thickness nm	Surface Roughness mmRms	Before Heating			After Heating		
				Stress Mpa*)	Stress x Film Thickness Pa · cm	Flatness nm	Stress Mpa*)	Stress x Film Thickness Pa · cm	Flatness nm
Stress Correction Film	Ru	10	0.15	+20 (+580)	+580	50	+138 (+4000)	+4000	
Multilayer Reflection Film	Mo/Si 40 periods	290	0.15	-450	-13050	1200	-200	-5800	
Stress Correction Film + Multilayer Reflection Film				-430	-12470	1150	-62	+1800	80

\*) The value outside of ( ) shows the film stress corresponding to the film thickness of the multilayer reflection film,  
the value inside of ( ) shows the film stress per unit film thickness